

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re patent application of

Burda, et al.

Serial No.: 1 10/711079

Group Art Unit: Unknown

Filing Date: 08/20/04_

Examiner: Unknown

For:

A METHOD AND SYSTEM FOR INTELLIGENT AUTOMATED RETICLE

MANAGEMENT

Commissioner of Patents P.O. Box 1450 Alexandria, VA 22313-1450

SUPPLEMENTAL INFORMATION DISCLOSURE STATEMENT

Sir:

Under the provisions of 37 CFR §1.97 through §1.99 and pursuant to applicants' duty of disclosure under 37 CFR §1.56, applicants respectfully bring the following documents, listed on the attached form PTO-1449, to the attention of the Examiner in charge of the above-identified application. Copies of the listed documents are provided herewith for the convenience of the Examiner. This citation does not constitute an admission that the references are relevant or material to the claims. They are only cited as constituting related art of which the applicants are aware.

It is respectfully requested that the listed references be considered by the Examiner and formally made of record in this application.

Please charge any deficiencies in fees and credit any overpayment of fees to Attorney's Deposit Account No. 09-0456.

Respectfully submitted,

DS. Rhy

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PILE/		Docket Number (Optional)	Application Number
P '%	•	BUR920040031US1	10/711079
MIR 3 D SOUTH ST	RMATION DISCLOSURE CITATION (Use several sheets if necessary)	Applicant(s) Burda, et al.	
AUG S	(Ose several sheets if necessary)	Filing Date	Group Art Unit
		08/20/04	Unknown
INITIAL	OTHER DOCUMENTS (Including Author,	Title, Date, Pertinent Pages, Etc.)	
MITAL	Nadoli, et al, "SIMULATION IN AUTOMATEI MANUFACTURING", Proceedings of the 1994	D MATERIAL HANDLING SYSTEM Winter Simulation Conference, pp. 89	IS DESIGN FOR SEMICONDUCTOR
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	Park, et al., "ASSESSMENT OF POTENTIAL OF MANAGEMENT USING DISCRETE EVENT S 856-864	GAINS IN PRODUCTIVITY DUE TO SIMULATION", Proceedings of the 1	O PROACTIVE RETICLE 999 Winter Simulation Conference, pp.
	Campbell, et al., "A MODEL OF A 300MM WAFER FABRICATION LINE", Proceedings of the 1999 Winter Simulation Conference, pp. 909-911 Lee, et al., "DISPATCHING HEURISTIC FOR WAFER FABRICAITON", Proceedings of the 2001 Winter Simulation Conference, pp. 1215-1219		
	White, Jr., et al., "OPERATIONAL SIMULATION OF AN X-RAY LITHOGRAPHY CELL: COMPARISON OF 200MM AND 300MM WAFERS", Proceedings of the 1999 Winter Simulation Conference, pp. 865-874		
·	Pierce, et al., "MODELING AND SIMULATION OF MATERIAL HANDLING FOR SEMICONDUCTOR WAFER FABRICATION", Proceedings of the 1994 Winter Simulation Conference, pp. 900-906		
	Robinson, et al., "CAPACITY PLANNING FOR SEMICONDUCTOR WAFER FABRICATION WITH TIME CONSTRAINTS BETWEEN OPERATIONS", Proceedings of the 1999 Winter Simulaiton Conference, pp. 880-887		
EXAMINER		DATE CONSIDERED	
*EXAMINER: Initia	l if citation considered, whether or not citation is in conform	nance with MPEP Section 609: Draw line	through citation if not in conformance and
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not considered. Include copy of this form with next communication to applicant.